TDDFT for extended systems I: Plasmons

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Benasque, September 2016



classical plasma oscillations

experimental observation of plasmons

The homogeneous electron gas: how to calculate plasmons

Plasmons in TDDFT

Plasmon damping

Nanoscale systems and plasmonics



Classical bulk motion of charge in a solid



A slab of electrons moving back and forth on top of a slab of neutralizing positive charge: **plasma oscillations**.



Uniform electric field caused by surface charge: $E = 4\pi en\delta$

Total force on all electrons:
$$F = enVE = -4\pi n^2 e^2 V \delta$$

Set force equal to total mass times acceleration: $F=M\delta$

$$-4\pi n^2 e^2 V \delta = m V \ddot{\delta} \implies \ddot{\delta} = -\frac{4\pi n e^2}{m} \delta$$
Plasma frequency: $\omega_{pl}^2 = \frac{4\pi n e^2}{m}$



Some numbers

Table 2 Volume plasmon energies, in eV

Material	Observed	Calculated	
		$\hbar \omega_p$	$\hbar ilde{\omega}_p$
Metals			
Li	7.12	8.02	7.96
Na	5.71	5.95	5.58
K	3.72	4.29	3.86
Mg	10.6	10.9	٨
Al	15.3	15.8	

includes ionic background

Plasmons



Figure 6 Creation of a plasmon in a metal film by inelastic scattering of an electron. The incident electron typically has an energy 1 to 10 keV; the plasmon energy may be of the order of 10 eV. An event is also shown in which two plasmons are created.

Plasmons are quantized excitations of collective longitudinal waves of the electron gas.

They are not optically excited, but by scattering with electrons or photons.



Figure 7 A spectrometer with electrostatic analyzer for the study of plasmon excitation by electrons. (After J. Daniels et al.)



Electron loss spectra



Figure 8 Energy loss spectra for electrons reflected from films of (a) aluminum and (b) magnesium, for primary electron energies of 2020 eV. The 12 loss peaks observed in Al are made up of combinations of 10.3 and 15.3 eV losses, where the 10.3 eV loss is due to surface plasmons and the 15.3 eV loss is due to volume plasmons. The ten loss peaks observed in Mg are made up of combinations of 7.1 eV surface plasmons and 10.6 eV volume plasmons. Surface plasmons are the subject of Problem 1. (After C. J. Powell and J. B. Swan.)



Electron loss spectra



at low momentum: surface and volume plasmon

at large momentum transfer:

- double scattering
- Landau damping

A. vom Felde, J. Sprösser-Prou, and J. Fink, PRB **40**, 10181 (1989)



The history of plasmons

PHYSICAL REVIEW

VOLUME 85, NUMBER 2

JANUARY 15, 1952

A Collective Description of Electron Interactions: II. Collective vs Individual Particle Aspects of the Interactions

DAVID PINES Randal Morgan Laboratory of Physics, University of Pennsylvania, Philadelphia, Pennsylvania

AND

DAVID BOHM* Palmer Physical Laboratory, Princeton University, Princeton, New Jersey (Received September 28, 1951)

Plasmons: proposed by David Pines in 1952-55

Excitations in finite and extended systems $\chi(\mathbf{r}, \mathbf{r}', \omega) = \lim_{\eta \to 0^+} \left[\sum_{j} \frac{\langle \Psi_0 | \hat{n}(\mathbf{r}) | \Psi_j \rangle \langle \Psi_j | \hat{n}(\mathbf{r}') | \Psi_0 \rangle}{\omega - E_j + E_0 + i\eta} + c.c.(\omega \to -\omega) \right]$ Ω_i

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The full many-body response function has poles at the exact excitation energies



- Discrete single-particle excitations merge into a continuum (branch cut in frequency plane)
- New types of <u>collective excitations</u> appear off the real axis (finite lifetimes)



Kohn-Sham response function:

$$\chi_{s}(\mathbf{r},\mathbf{r}',\omega) = \sum_{j,k}^{\infty} (f_{k} - f_{j}) \frac{\varphi_{j}(\mathbf{r})\varphi_{k}^{*}(\mathbf{r})\varphi_{j}^{*}(\mathbf{r}')\varphi_{k}(\mathbf{r}')}{\omega - (\varepsilon_{j} - \varepsilon_{k}) + i\eta}$$

Homogeneous electron gas:

$$\varphi_{\mathbf{k}}(\mathbf{r}) = \frac{1}{\sqrt{V}} e^{i\mathbf{k}\cdot\mathbf{r}}$$

Lindhard function:

$$\chi_{s}(q,\omega) = 2\int \frac{d^{3}k}{(2\pi)^{3}} \left[\frac{\theta(k_{F}-k)}{\omega-\mathbf{k}\cdot\mathbf{q}-q^{2}/2+i\eta} - \frac{\theta(k_{F}-k)}{\omega+\mathbf{k}\cdot\mathbf{q}+q^{2}/2+i\eta} \right]$$

Giuliani and Vignale, Quantum Theory of the Electron Liquid (2005)



Full interacting response function:

$$\chi(q,\omega) = \frac{\chi_s(q,\omega)}{1 - [v_q + f_{xc}(q,\omega)]\chi_s(q,\omega)}$$

Poles of the full response function:



Full interacting response function:

$$\chi(q,\omega) = \frac{\chi_s(q,\omega)}{1 - [v_q + f_{xc}(q,\omega)]\chi_s(q,\omega)}$$

Poles of the full response function:

Poles of the Lindhard function give the particle-hole continuum



Particle-hole continuum



In the ground state, all single-particle states inside the **Fermi sphere** are filled. A **particle-hole excitation** connects an occupied single-particle state inside the Fermi sphere with an empty state outside.

$$\chi_{s}(q,\omega) = 2\int \frac{d^{3}k}{(2\pi)^{3}} \left[\frac{\theta(k_{F}-k)}{\omega-\mathbf{k}\cdot\mathbf{q}-q^{2}/2+i\eta} - \frac{\theta(k_{F}-k)}{\omega+\mathbf{k}\cdot\mathbf{q}+q^{2}/2+i\eta} \right]$$

Denominator vanishes for frequency range

$$\frac{q^2}{2} - qk_F \leq \omega \leq \frac{q^2}{2} + qk_F$$



Particle-hole continuum

 $\frac{q^2}{2} - qk_F \leq \omega \leq \frac{q^2}{2} + qk_F$ Denominator vanishes for frequency range 5 ω 4 3 $k_{F} = 1$ 2 1 0 0.5 1.5 2 2.5 3.5 1 3 0 4



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Full interacting response function:

$$\chi(q,\omega) = \frac{\chi_s(q,\omega)}{1 - [v_q + f_{xc}(q,\omega)]\chi_s(q,\omega)}$$

Poles of the full response function:

Vanishing denominator gives the plasmons

$$[v_q + f_{xc}(q,\omega)]\chi_s(q,\omega) = 1$$





Random Phase Approximation (RPA):

$$v_q \chi_s(q,\omega) - 1 = 0$$

RPA dielectric function



$$\chi_{s}(q,\omega) = 2\int \frac{d^{3}k}{(2\pi)^{3}} \left[\frac{\theta(k_{F}-k)}{\omega-\mathbf{k}\cdot\mathbf{q}-q^{2}/2+i\eta} - \frac{\theta(k_{F}-k)}{\omega+\mathbf{k}\cdot\mathbf{q}+q^{2}/2+i\eta} \right]$$
$$\chi_{s}(q,\omega) = \frac{1}{2\pi^{2}} \int_{0}^{k_{F}} k^{2} dk \int_{0}^{\pi} \sin\theta d\theta \left[\frac{1}{\omega-\mathbf{k}\cdot\mathbf{q}-q^{2}/2} - \frac{1}{\omega+\mathbf{k}\cdot\mathbf{q}+q^{2}/2} \right]$$
$$= \frac{1}{\pi^{2}\omega^{2}} \int_{0}^{k_{F}} k^{2} dk \int_{0}^{\pi} \sin\theta d\theta [kq\cos\theta+q^{2}/2] + O(q^{4})$$

One finds

$$\chi_{s}(q,\omega) = \frac{k_{F}^{3}}{3\pi^{2}} \frac{q^{2}}{\omega^{2}} \left[1 + \frac{3k_{F}^{2}q^{2}}{5\omega^{2}} + \dots \right]$$



$$\begin{bmatrix} \frac{4\pi}{q^2} + f_{xc}(q,\omega) \\ \chi_s(q,\omega) = 1 \end{bmatrix} \chi_s(q,\omega) = 1$$
$$\chi_s(q,\omega) = \frac{k_F^3}{3\pi^2} \frac{q^2}{\omega^2} \left[1 + \frac{3k_F^2 q^2}{5\omega^2} + \dots \right]$$

To order q^2 , one finds

$$\omega(q) = \omega_{pl} \left[1 + \left(\frac{3k_F^2}{10\omega_{pl}^2} + \frac{1}{8\pi} f_{xc}(0,\omega_{pl}) \right) q^2 \right]$$



Plasmon dispersion



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Plasmon dispersion



K. Tatarczyk, A. Schindlmayr, and M. Scheffler, PRB 63, 235106 (2001)



Plasmons in different dimensions

Bulk plasmon: $\omega(q) = \omega_p + \alpha q^2 + \dots$ ω 2D plasmon: $\omega(q) = \beta \sqrt{q} + \dots$ ω Intersubband plasmons: $\omega(q) = (\varepsilon_2 - \varepsilon_1) \pm \Delta_{Hxc}^{c,s} + \dots$





- 1. Derive the small-q plasmon dispersions of an electron gas in 3D, 2D, and 1D
- 2. Obtain plasmons starting from the Casida equation in TDDFT. In other words, show that, for an electron gas,

$$\begin{pmatrix} \mathbf{A} & \mathbf{K} \\ \mathbf{K}^* & \mathbf{A}^* \end{pmatrix} \begin{pmatrix} \mathbf{X} \\ \mathbf{Y} \end{pmatrix} = \Omega \begin{pmatrix} -\mathbf{1} & \mathbf{0} \\ \mathbf{0} & \mathbf{1} \end{pmatrix} \begin{pmatrix} \mathbf{X} \\ \mathbf{Y} \end{pmatrix} \implies \begin{bmatrix} \frac{4\pi}{q^2} + f_{xc}^{adia}(q) \end{bmatrix} \chi_s(q, \omega) = 1$$

- 3. Convince yourself that the Tamm-Dancoff approximation fails completely for plasmons.
- 4. Write a simple code to calculate the full plasmon dispersions.



Excitations in nanostructures



Vertical excitations: no momentum change, $k_{\parallel} = 0$

Nonvertical excitations: finite momentum transfer, $k_{\parallel} > 0$



Inter-versus intrasubband dynamics



intersubband plasmon: <u>perpendicular</u> to the plane





intrasubband plasmon (charge/spindensity wave): within the plane



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Intersubband plasmon dispersions





VOLUME 63, NUMBER 15

PHYSICAL REVIEW LETTERS

9 OCTOBER 1989

Large Exchange Interactions in the Electron Gas of GaAs Quantum Wells

A. Pinczuk, S. Schmitt-Rink, G. Danan, J. P. Valladares, L. N. Pfeiffer, and K. W. West AT&T Bell Laboratories, Murray Hill, New Jersey 07974





Plasmon damping: adiabatic xc kernel

1.75



Should have finite (but large) lifetime!

Plasmon decays into individual particle-hole excitations (Landau damping)

How does TDDFT do this?

Adiabatic xc kernel: ω is real outside the particle-hole continuum

 $\frac{4\pi}{a^2} + f_{xc}^{adia}(q) \left| \chi_s(q,\omega) = 1 \right|$

Intrinsic plasmon damping mechanism





- Plasmon has energy and momentum different from any single p-h pair
 plasmon is robust
- But, can find two p-h pairs at right energy, and combined right total momentum

→ (weak) decay channel, requires Coulomb correlation beyond ALDA



The VK-functional of current-TDDFT

$$\mathbf{A}_{xc,1}^{VK}(\mathbf{r},\omega) = \mathbf{A}_{xc,1}^{ALDA}(\mathbf{r},\omega) - \frac{1}{i\omega n_0(\mathbf{r})} \nabla \cdot \vec{\sigma}_{xc}(\mathbf{r},\omega)$$

xc viscoelastic stress tensor:

$$\sigma_{xc,\mu\nu}(\omega) = \eta_{xc} \left(\nabla_{\nu} u_{1,\mu} + \nabla_{\mu} u_{1,\nu} - \frac{2}{3} \nabla \cdot \mathbf{u}_1 \delta_{\mu\nu} \right) + \zeta_{xc} \nabla \cdot \mathbf{u}_1 \delta_{\mu\nu}$$

$$\mathbf{u}(\mathbf{r},\omega) = \mathbf{j}(\mathbf{r},\omega) / n_0(\mathbf{r}) \quad \text{velocity field}$$

G. Vignale and W. Kohn, PRL 77, 2037 (1996)
G. Vignale, C.A.U., and S. Conti, PRL 79, 4878 (1997)
C.A.U. and G. Vignale, PRB 65, 245102 (2002)

Gives correct description of plasmon damping, but tends to overdamp as soon as the plasmon is less "hydrodnamic". Not recommended for excitations in atoms and molecules.



Plasmon excitations in bulk metals



- In general, excitations in (simple) metals very well described by ALDA.
- •Time-dependent Hartree (=RPA) already gives the dominant contribution
- f_{xc} typically gives some (minor) corrections (damping!)
- •This is also the case for 2DEGs in doped semiconductor heterostructures

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Plasmon excitations in metal clusters



Surface plasmons ("Mie plasmon") in metal clusters are very well reproduced within ALDA.

Plasmonics: mainly using classical electrodynamics, not quantum response, but TDDFT becoming more and more widely used



Oscillation of a uniformly charged sphere against neutralizing background.

A standard result from electrostatics: conducting sphere in a uniform electric field:

Surface charge density:
$$3 - 2$$





Mie plasmons



Displacing two charged spheres, we find $\sigma = end\cos\theta$

This surface charge is identical to what one gets in an electric field, so

$$\sigma = \frac{3}{4\pi} E_0 \cos \theta = end \cos \theta$$

Total force on all electrons:

$$F = enVE_0 = -\frac{4\pi}{3}n^2e^2Vd$$

Set force equal to total mass times acceleration: $F = mnV\hat{\delta}$



Mie scattering

Rayleigh scattering: $\lambda >> d$ Rayleigh scattering intensity: $I \sim I_0 \frac{1 + \cos^2 \theta}{\lambda^4}$ (explains why sky is blue) $\lambda \ll d$ Rayleigh-Gans-Debye scattering: $\lambda \approx d$ Mie scattering:

Gustav Mie 1869-1957

Metal nanoparticles:



diameter d: 1 – 100 nm



Absorption changes with particle size and refractive index of the medium.

M.A. van Dijk, PhD thesis (2007)

Localization of optical fields: nanoplasmonics



Figure 4.4.: (a) Scattering cross section of a gold nanotriangle $(55 \times 50 \times 8 \text{ nm}, n_b = 1.34)$. The panels (b) and (c) show the electric field at the resonance energy of 792 nm at the particle surface and on the outside, respectively. (Also see Fig. 3.7.) A. Trügler, PhD thesis (2011)



Hot spots



Figure 3. Hot spots, nanoscale enhancements in the local electric field *E* compared to an incident field E_{or} are calculated for certain metal nanostructures: (a) the sharp end of a gold

tip excited by a vertically polarized laser field (adapted from ref. 4); (b) a fractal cluster of silver nanoparticles (inset) whose resonance enhancement and specific morphologies can magnify, at the hottest spot, the local fields by a factor of nearly 300 (adapted from ref. 3); and (c) a self-similar nanolens whose geometrical arrangement of spheres concentrates optical energy, from bigger spheres to smaller ones, in the tight gaps between them.⁵ In the hottest spot, the field is enhanced by a factor of 1200.

M.I. Stockman, Physics Today (2011)

Hot spots arise from the multiplication of the SP enhancement factors, constructive interference of SP fields from different particles, and additional enhancement due to sharp tips and small gaps.

Nanoplasmonics with TDDFT: local E-fields



A. Varas, P. Garcia-Gonzalez, J. Feist, F.J. Garcia-Vidal & A. Rubio, Nanophotonics (2016)

- TDDFT is very good for collective plasmon excitations in metallic systems (mostly small corrections to RPA)
- There is a lot of activity applying TDDFT to nanoplasmonics (beyond linear response!)

Challenges for TDDFT:

- plasmon damping (nonadiabatic xc effects)
- collective spin modes (no RPA, purely xc, hence very sensitive to choice of functional)

N. H. March and M. P. Tosi, Advances in Physics 44, 299 (1995)
S. M. Morton, D. W. Silverstein & L. Jensen, Chem. Rev. 111, 3962 (2011)
E. B. Guidez and C. M. Aikens, Nanoscale 6, 11512 (2014)
A. Varas, P. Garcia-Gonzalez, J. Feist, F.J. Garcia-Vidal & A. Rubio, Nanophotonics (2016)